

Notice of References Cited

Application/Control No.

09/451,619

Applicant(s)/Patent Under Reexamination MORI, SEIICHI

Examiner

Howard Weiss

Art Unit
Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification	
	Α	US-5,904,518	05-1999	Komori et al.	438	201
	В	US-5,640,345	06-1997	Okuda et al.	365	184
	С	US-5,631,179	05-1997	Sung et al.	438	264
	D	US-6,130,452	10-2000	Lu et al.	257	315
	Ε	US-5,345,104	09-1994	Prall et al.	257	607
	F	US-				
	G	US-				
	Н	US-				
		US-				
	J	US-				
	К	US-				
	L	US-				
	М	US-				

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	S					
	Т					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)				
	U	"An EEPROM Cell with Asymetrical Sidewall to Minimize Drain Couplings", April 1993, IBM technical Disclosure Bulletin, Vol. 36, No. 04, pp. 45-7				
	٧	Kume, H., et al., "A Flash-Erase EEPROM Cell with an Asymetric Source and Drain Structure", 1987, IEDM 87, pp. 560-3				
	w					
	х					

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.